

REPORT DOCUMENTATION PAGE			Form Approved OMB NO. 0704-0188		
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1. REPORT DATE (DD-MM-YYYY) 13-11-2018		2. REPORT TYPE Final Report		3. DATES COVERED (From - To) 15-Aug-2013 - 14-Aug-2016	
4. TITLE AND SUBTITLE Final Report: 1.2.2. Nanoelectronics and Nanosensors for Army Applications: Hexagonal Atomic Sheets of Silicon (Silicene); Towards Heterogeneous Layered Solids			5a. CONTRACT NUMBER W911NF-13-1-0364		
			5b. GRANT NUMBER		
			5c. PROGRAM ELEMENT NUMBER 611102		
			5d. PROJECT NUMBER		
6. AUTHORS			5e. TASK NUMBER		
			5f. WORK UNIT NUMBER		
7. PERFORMING ORGANIZATION NAMES AND ADDRESSES University of Texas at Austin 101 East 27th Street Suite 5.300 Austin, TX 78712 -1532			8. PERFORMING ORGANIZATION REPORT NUMBER		
9. SPONSORING/MONITORING AGENCY NAME(S) AND ADDRESS (ES) U.S. Army Research Office P.O. Box 12211 Research Triangle Park, NC 27709-2211			10. SPONSOR/MONITOR'S ACRONYM(S) ARO		
			11. SPONSOR/MONITOR'S REPORT NUMBER(S) 63801-MS.3		
12. DISTRIBUTION AVAILABILITY STATEMENT Approved for public release; distribution is unlimited.					
13. SUPPLEMENTARY NOTES The views, opinions and/or findings contained in this report are those of the author(s) and should not be construed as an official Department of the Army position, policy or decision, unless so designated by other documentation.					
14. ABSTRACT					
15. SUBJECT TERMS					
16. SECURITY CLASSIFICATION OF:			17. LIMITATION OF ABSTRACT UU	15. NUMBER OF PAGES	19a. NAME OF RESPONSIBLE PERSON Deji Akinwande
a. REPORT UU	b. ABSTRACT UU	c. THIS PAGE UU			19b. TELEPHONE NUMBER 512-471-4345

RPPR Final Report
as of 20-Nov-2018

Agency Code:

Proposal Number: 63801MS

Agreement Number: W911NF-13-1-0364

INVESTIGATOR(S):

Name: Deji Akinwande
Email: deji@ece.utexas.edu
Phone Number: 5124714345
Principal: Y

Organization: **University of Texas at Austin**

Address: 101 East 27th Street, Austin, TX 787121532

Country: USA

DUNS Number: 170230239

EIN: 746000203

Report Date: 14-Nov-2016

Date Received: 13-Nov-2018

Final Report for Period Beginning 15-Aug-2013 and Ending 14-Aug-2016

Title: 1.2.2. Nanoelectronics and Nanosensors for Army Applications: Hexagonal Atomic Sheets of Silicon (Silicene); Towards Heterogeneous Layered Solids

Begin Performance Period: 15-Aug-2013

End Performance Period: 14-Aug-2016

Report Term: 0-Other

Submitted By: Deji Akinwande

Email: deji@ece.utexas.edu

Phone: (512) 471-4345

Distribution Statement: 1-Approved for public release; distribution is unlimited.

STEM Degrees:

STEM Participants: 1

Major Goals: This research effort focused on pioneering epitaxial synthesis of silicene based on innovative growth approaches and systematic elucidation of the growth kinetics. In addition, fabricated silicene devices was experimentally investigated for the first time in order to shed light on the electronic properties and device physics. The proposed research is organized into three central tasks to address the most pressing challenges facing silicene research.

Task 1: Synthesis of Silicene. The growth of silicene will be accomplished by evaporation of silicon atoms on epitaxial Ag(111) surfaces which offers an hexagonal lattice structure for achieving single-crystal honeycomb films. In addition, alternative transitional metal epitaxial substrates will be investigated that do not react with silicon but can promote epitaxial growth.

Task 2: Experimental Device Studies. Benign wet and dry transfer methods will be investigated including polymer assisted, and direct delamination transfers of the silicene monolayers from the Ag surface to arbitrary insulating substrates for device studies. This task will overcome one of the major barriers to progress regarding material and device studies.

Accomplishments: -Discovery of Ag/mica substrate stack for epitaxial growth of silicene.
-Invention of a method to transfer silicene after growth onto insulating substrates for the first time.
-Demonstration of air-stable encapsulated silicene.
-Demonstration of electrical field-effect control of silicene proving its predicted Dirac properties.

Training Opportunities: Nothing to Report

Results Dissemination: The findings were published in peer-reviewed journals and presented at relevant conferences. The publications and conference are listed in the project attachment report.

Honors and Awards: U.S. Presidential (PECASE) Award from President Obama
Editor, Nature NPJ 2D Materials and Applications
IEEE Nanotechnology Early Career Award

Protocol Activity Status:

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Technology Transfer: We established collaboration with ARDEC to study phase transitions in 2D or topological materials. The experimental work was done in synergy with the theoretical/experimental studies performed by Dr. Venkataraman Swaminathan and Mr Dan Kaplan of US-ARMY ARDEC. The samples were prepared by ARDEC scientists who were collaborating with Drs. Patrick Taylor and Patrick Folkes at the Army Research Laboratory. The experimental results obtained at UT-Austin was shared on a regular basis with the ARDEC team to develop a comprehensive understanding of the pressure induced phase transitions in Pb-based IV-VI semiconductors. The ARDEC team visited UT-Austin for extended experiments. A peer-review publication resulted from our joint findings.

Invention Disclosure was filed and patent based on innovative methods to transfer and make silicene devices is pending.

PARTICIPANTS:

Participant Type: PD/PI

Participant: Deji Akinwande

Person Months Worked: 1.00

Funding Support:

Project Contribution:

International Collaboration:

International Travel:

National Academy Member: N

Other Collaborators:

Participant Type: Postdoctoral (scholar, fellow or other postdoctoral position)

Participant: Li Tao

Person Months Worked: 6.00

Funding Support:

Project Contribution:

International Collaboration:

International Travel:

National Academy Member: N

Other Collaborators:

ARTICLES:

Publication Type: Journal Article

Peer Reviewed: Y

Publication Status: 1-Published

Journal: Journal of Applied Physics

Publication Identifier Type: DOI

Publication Identifier: 10.1063/1.5018857

Volume: 123 Issue: 11

First Page #: 115903

Date Submitted: 11/13/18 12:00AM

Date Published: 3/1/18 12:00PM

Publication Location:

Article Title: Structural, vibrational, and electronic topological transitions of Bi

Authors: Joon-Seok Kim, Rinkle Juneja, Nilesh P. Salke, Witold Palosz, Venkataraman Swaminathan, Sudhir Tri

Keywords: 2d materials

Abstract: Topological insulators have been the subject of intense research interest due to their unique surface states that are topologically protected against scattering or defects. However, the relationship between the crystal structure and topological insulator state remains to be clarified. Here, we show the effects of hydrostatic pressure on the structural, vibrational, and topological properties of the topological insulator Bi_{1.5}Sb_{0.5}Te_{1.8}Se_{1.2} up to 45 GPa using X-ray diffraction and Raman spectroscopy in a diamond anvil cell, together with first-principles theoretical calculations.

Distribution Statement: 1-Approved for public release; distribution is unlimited.

Acknowledged Federal Support: Y

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PATENTS:

Intellectual Property Type: Patent

Date Received: **13-Nov-2018**

Patent Title: Integration of air-sensitive two-dimensional materials on arbitrary substrates for the manufacturing of electronic devices

Patent Abstract: A field-effect transistor and method for fabricating such a field-effect transistor that utilizes an air

Patent Number: US20180013009A1

Patent Country: USA

Application Date: 13-Jul-2015

Application Status: 2

Date Issued:

ARO Project Summary contents

1. Title of the Proposal, Grant#, PI's Name, Institution

Hexagonal Atomic Sheets of Silicon (Silicene), W911NF-13-1-0364, Deji Akinwande, University of Texas-Austin

2. Objective of the proposal

The objective of this research effort is fundamental growth and investigation of silicene 2D buckled atomic layer that can translate into long-term air-stable silicene materials for basic material physics and device experimental studies. A supplemental research with Army collaborators on phase transitions was also investigated.

3. Technical Approach

Silicene was previously grown on Ag substrates. We determined this was not suitable for downstream processing for further material studies. We discovered that Ag thin films on mica was a more suitable substrate since the Ag could be removed as a sacrificial layer during transfer and the mica could be recycled for subsequent growth. Afterwards, we developed a completely dry transfer process which protected the silicene layer from chemicals since the silicene is extremely air-sensitive and not robust against common solvents and acids. Lastly we developed an encapsulation layer that protected the silicene in the environment and enabled microfabrication for experimental materials and device studies for the first time.

4. Scientific Accomplishments

- Discovery of Ag/mica substrate stack for epitaxial growth of silicene.
- Invention of a method to transfer silicene after growth onto insulating substrates for the first time (shown below).
- Demonstration of air-stable encapsulated silicene.
- Demonstration of electrical field-effect control of silicene proving its predicted Dirac properties.

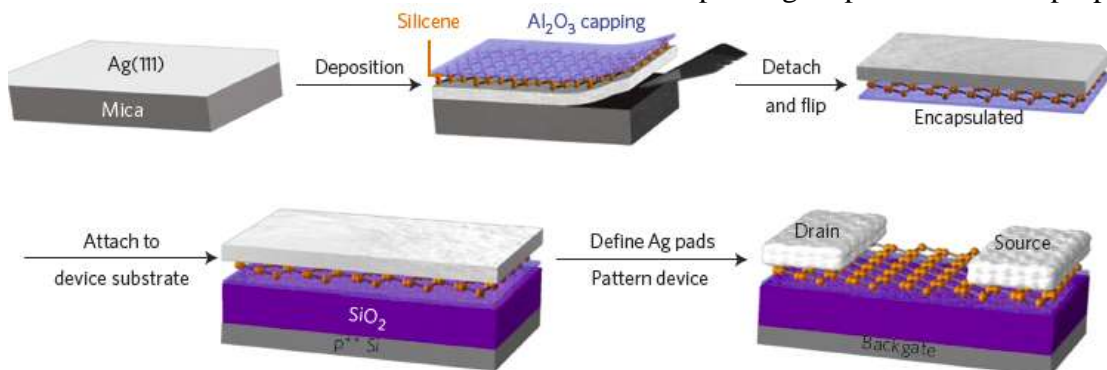


Fig: Invention of a new transfer method named, Silicene Encapsulated Delamination with Native Electrode (SEDNE) that includes the following key steps: epitaxial growth of silicene on crystallized Ag(111) thin film on mica, in-situ Al₂O₃ capping, encapsulated delamination transfer of silicene, and native contact electrodes formation to enable back-gated silicene transistors for the first time.

5. Other Metrics- Tech transfer if any

This project was in collaboration with Army Research Laboratory (ARL) and they engaged in both basic and applied aspects of the properties of this material for Army technology.

6. Any Significant Faculty awards, a list of papers/patents related to this project

Awards

- IEEE Early Career Award in Nanotechnology, 2015
- UT-Austin Jack Kilby Endowed Faculty Fellowship, 2015

Papers

- i. J.-S. Kim, R. Juneja, N. P. Salke, W. Palosz, V. Swaminathan, S. Trivedi, A. K. Singh, **D. Akinwande**, and J.-F. Lin, "Structural, vibrational, and electronic topological transitions of $\text{Bi}_{1.5}\text{Sb}_{0.5}\text{Te}_{1.8}\text{Se}_{1.2}$ under pressure," *Journal of Applied Physics*, vol. 123, p. 115903, 2018.
- ii. L. Tao, E. Cinquanta, D. Chiappe, C. Grazianetti, M. Fanciulli, M. Dubey, A. Molle, and **D. Akinwande**, "Silicene field-effect transistors operating at room temperature," *Nat Nano*, Feb. 2015.
- iii. **D. Akinwande**, "(Invited) Phosphorene and Silicene: Complexity and Opportunity in Buckled Atomic Sheets," MRS Fall meeting, Boston, Dec. 2015.
- iv. **D. Akinwande**, "(Invited) Silicene Field-Effect Transistors," MRS Spring meeting, San Francisco, CA, 2015.

Patent

Li Tao and **Deji Akinwande**, "Integration of Air-Sensitive Two-Dimensional Materials on Arbitrary Substrates for the Manufacturing of Electronic Devices," Invention Disclosure, 2015, Processing by the University of Texas at Austin.

7. Army Relevance: (Army related future applications that you think could be impacted by the current basic research project)

Silicene is a leading candidate for future quantum electronics based on its intriguing topological phase properties, which is a new state of matter discovered in the last decade. The state of matter promises low-energy efficient electronic systems that are protected from scattering by defects and impurities unlike anything seen in other states of matter. Army materials and electronics/sensor technologies stand to benefit with further research and development to exploit this phenomena in silicene and related buckled materials. ARDEC has interest in this type of 2D materials technology and participated in a workshop with the principal investigator and researchers at ARL-SEDD.

7. Army Relevance:

We established collaboration with ARDEC to study phase transitions in 2D or topological materials. The experimental work was done in synergy with the theoretical/experimental studies performed by Dr. Venkataraman Swaminathan and Mr Dan Kaplan of US-ARMY ARDEC. The samples were prepared by ARDEC scientists who were collaborating with Drs. Patrick Taylor and Patrick Folkes at the Army Research Laboratory. The experimental results obtained at UT-Austin was shared on a regular basis with the ARDEC team to develop a comprehensive understanding of the pressure induced phase transitions in Pb-based IV-VI semiconductors. The ARDEC team as well as collaborators from the Army Research Laboratory visited UT-Austin for extended experiments. A peer-review publication resulted from our joint findings. The paper is listed above.